

L Number	Hits	Search Text	DB	Time stamp
1	248	(dopant impurity) near3 (layer film) same (anodic anode anodization) near10 (oxid\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/08 07:04
2	21	((dopant impurity) near3 (layer film) same (anodic anode anodization) near10 (oxid\$5)) and (separat\$3 cleav\$3 break\$3) near5 substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/08 07:06
3	14	((((dopant impurity) near3 (layer film) same (anodic anode anodization) near10 (oxid\$5)) and (separat\$3 cleav\$3 break\$3) near5 substrate) and @ad<19981222	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/08 07:06